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Handbook Of Semiconductor Wafer Cleaning

Handbook of Silicon Wafer Cleaning Technology, Third Edition, provides an in-depth discussion of cleaning, etching and surface conditioning for semiconductor applications. The fundamental physics and chemistry associated with wet and plasma processing are reviewed, including surface and colloidal aspects.

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The cleaning of semiconductor wafers has become one of the most critical operations in the fabrication of semiconductor devices. The considerable body of technical and scientific literature is widely dispersed in numerous journals and symposia proceedings. This book brings together in one volume all pertinent knowledge on semiconductor wafer cleaning and its associated scientific and technical ...

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Handbook of Semiconductor Wafer Cleaning Technology I ...

498 Handbook of Semiconductor Wafer Cleaning Technology electrical contacts, thus eliminating any additional processing steps. It can be used with a bare wafer surface or with dielectric coatings ...

HANDBOOK OF SEMICONDUCTOR WAFER CLEANING TECHNOLOGY

The second Edition of the Handbook of Silicon Wafer Cleaning Technology is intended to provide knowledge of wet, plasma, and other surface conditioning techniques used to manufacture integrated circuits.The integration of the clean processes into the device manufacturing flow will be presented with respect to other manufacturing steps such as thermal, implant, etching, and photolithography ...

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Prior to forming a consulting company, Karen was employed at Novellus Systems, AMD, and Cypress Semiconductor. She has published more than 30 technical publications, has been awarded seven patents, and is co-editor of Handbook of Silicon Wafer Cleaning Technology.

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"The cleaning of semiconductor wafers has become one of the most critical operations in the fabrication of semiconductor devices. The considerable body of technical and scientific literature is widely dispersed in numerous journals and symposia proceedings. This book brings together in one volume all pertinent knowledge on semiconductor wafer cleaning and its associated scientific and ...

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Cleaning Procedures for Silicon Wafers INRF application note Process name: SOLVENTCLEAN + RCA01 + HFDIP . W. Kern and J. Vossen, Thin Film Processes, Academic Press: New York, 1978, Ch V-1 . W. Kern and Ed., Handbook of Semiconductor Cleaning Technology, Noyes Publishing: Park Ridge, NJ, 1993 Ch 1. Checklist

Cleaning Procedures for Silicon Wafers

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Handbook of Silicon Wafer Cleaning Technology - 3rd Edition

- Focused on silicon wafer cleaning techniques including wet, plasma, and other surface conditioning techniques used to manufacture integrated circuits- As this book covers the major technologies for removing contaminants, it is a reliable reference for anyone that manufactures integrated circuits, or supplies the semiconductor and microelectronics industries- Covers processes and equipment ...

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